

# Contact line curvature-induced molecular misorientation of a surface energy patterned organic semiconductor in meniscus-guided coating

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### ▶ To cite this version:

Do-Kyung Kim, Premkumar Vincent, Jaewon Jang, In Man Kang, Hyeok Kim, et al.. Contact line curvature-induced molecular misorientation of a surface energy patterned organic semiconductor in meniscus-guided coating. Applied Surface Science, 2020, 504, pp.144362. 10.1016/j.apsusc.2019.144362. hal-02395157

## HAL Id: hal-02395157 https://u-paris.hal.science/hal-02395157

Submitted on 20 Dec 2019

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Elsevier Editorial System(tm) for Applied

Manuscript Draft

Surface Science

Manuscript Number:

Title: Contact line curvature-induced molecular misorientation of a surface energy patterned organic semiconductor in meniscus-guided coating

Article Type: Full Length Article

Keywords: Molecular misorientation; surface energy patterning; organic

semiconductor; meniscus-guided coating

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Abstract: The printing of organic semiconductors (OSCs) by means of meniscus guided coating (MGC) has great potential for the fabrication of high-performance, uniform, and large area flexible electronics. Furthermore, surface energy patterning allows low-cost, large area manufacturing, and is a requirement for device isolation to achieve accurate drive and to minimize power consumption. We investigated the morphological and electrical characteristics of surface energy patterned OSCs coated using the MGC method. A unique phenomenon, contact line curvature-induced molecular misorientation effect, which occurs in the patterning of OSCs with the MGC method, is demonstrated. This effect is highly dependent on the pattern width which decided contact line curvature. It influences the charge transport properties and hence the field-effect mobility of organic thin-film transistors (OTFTs). OTFTs in widths ranging from 50 to 500  $\mu m$  were fabricated. The highest misorientation angle was induced in the  $50 \ \mu m$  pattern width and the corresponding OTFTs exhibited the highest mobility.

Cover

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- 3 guided coating

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## 17 Contact line curvature-induced molecular misorientation of a 18 surface energy patterned organic semiconductor in meniscus-19 guided coating

21 Abstract

The printing of organic semiconductors (OSCs) by means of meniscus guided coating (MGC) has great potential for the fabrication of high-performance, uniform, and large area flexible electronics. Furthermore, surface energy patterning allows low-cost, large area manufacturing, and is a requirement for device isolation to achieve accurate drive and to minimize power consumption. We investigated the morphological and electrical characteristics of surface energy patterned OSCs coated using the MGC method. A unique phenomenon, contact line curvature-induced molecular misorientation effect, which occurs in the patterning of OSCs with the MGC method, is demonstrated. This effect is highly dependent on the pattern width which decided contact line curvature. It influences the charge transport properties and hence the field-effect mobility of organic thin-film transistors (OTFTs). OTFTs in widths ranging from 50 to 500 µm were fabricated. The highest misorientation angle was induced in the 50 µm pattern width and the corresponding OTFTs exhibited the highest mobility.

#### 33 Keywords

34 Molecular misorientation, surface energy patterning, organic semiconductor, meniscus-guided coating

Introduction

Great expectations for next-generation electronics have prompted active research on solution-processed organic thin-film transistors (OTFTs) which can be front-running candidates for low-cost, large-area device manufacturing, and flexible active-matrix displays and sensors<sup>1-3</sup>. High electrical performance beyond that of amorphous silicon TFTs has been achieved in solution-processed OTFTs through the tuning of small molecule organic semiconductors (OSCs)<sup>4-7</sup>. One of the best tuning methods is to control the solution coating. In this regard, many solution coating techniques like inkjet printing, shearing, spin-coating, spray coating, dip-coating, blade-coating, and slot-die coating have been developed<sup>8-14</sup>. Among these methods, meniscus guided coating (MGC) methods, as in blading, shearing, or slit-die coating, which deposit solution directionally on the target substrate by the virtue of capillary force between the substrate and the coating head, have been extensively studied because of their special advantages<sup>15</sup>. They can form uniform thin films with easily controlled film thickness in large-area fabrication compared to other coating methods. Moreover, they induce molecular alignments, and in some cases molecular packing due to their directionality. As a result, the charge transport properties of small molecule OSCs are enhanced and high field-effect mobility can be achieved<sup>9</sup>.

Patterning of OSC thin films plays a significant role in the improvement of the electrical characteristics of OTFTs. Confinement of the OSCs through patterning suppresses leakage currents and crosstalk effect in integrated circuits, thus yielding more accurate TFT drive and lower power consumption<sup>16-18</sup>. These positive attributes have driven the development of various patterning methods for selective deposition of semiconductor thin films. Photolithography, template guided patterning, stamping, and chemical patterning have been introduced to pattern soluble OSCs <sup>19-21</sup>. In particular, chemical patterning that induces hydrophobic and hydrophilic region selectively through self-assembled monolayer formation or surface terminal group control has been widely studied due to its merits<sup>16-18,21</sup>. It is a facile method that does not require conventional photolithography and is not area constrained. This means that fewer process steps, lower manufacturing costs, and large-area fabrication can be achieved.

Nevertheless, many studies of MGC methods have been focused on improving unpatterned thin-film characteristics and TFT electrical performance by controlling coating velocity or solvents<sup>6,22,23</sup>. Although some reports have studied patterning methods and have fabricated patterned OTFTs, the morphological and electrical characteristics of MGC methods have not been fully understood. Furthermore, a unique

behavior of patterned small molecule OSCs that does not occur in an unpatterned layer when using MGC methods should be addressed.

67 In this study, we investigated the morphological and electrical characteristics of the surface energy 68 patterned bis (triisopropylsilylethynyl) (TIPS)-pentacene deposited with blade coating, one of the representative MGC methods. We observed the molecular misorientation that affected the charge 69 70 transport properties between source and drain electrodes was induced in the mesoscale patterned layer by 71 the contact line curvature of the blade coating process. In addition, the pattern width highly affected the 72 contact line curvature-induced molecular misorientation. To demonstrate the electrical result of this effect. 73 the OTFTs were fabricated with TIPS-pentacene thin films of various pattern widths. TIPS-pentacene thin 74 films patterned with a 50 µm width showed the lowest misorientation angle of 7.75°, while those 75 patterned with a 300 µm width exhibited the highest misorientation angle of 18°. Since the molecular 76 misorientation affected their charge transport, OTFTs patterned with 300 µm width showed the lowest field-effect mobility of  $0.216~\text{cm}^2~\text{V}^{-1}~\text{s}^{-1}$ . In contrast, the 50  $\mu m$  wide patterned OTFTs showed a 77 relatively high field-effect mobility of 0.317 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>, a more effective charge transport value. 78

#### Materials and methods

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Figure 1(a) shows a schematic of the OSC patterning process. Indium-tin oxide (ITO)-deposited glass was prepared for the substrate and gate electrodes of the TFTs. Cross-linked poly(4-vinyl phenol)(c-PVP), mixed with methylated poly(melamine-co-formaldehyde) at a mass ratio of 1:1.25 and dissolved in propylene glycol methyl ether acetate at 10 wt. % was spin coated on the ITO gates to form a polymer insulator. The substrate was spun at 3,000 revolutions per minute for 30 s and annealed at 200 °C for 1 h on a hot plate for cross-linking. For chemical patterning of the TIPS-pentacene, hydrophobic regions were generated through polydimethylsiloxane (PDMS) attachment on c-PVP and heated for 10 min at 120 °C. In this step, the methyl group, which is the surface terminal group of PDMS, was transferred onto the c-PVP insulator<sup>18</sup>. To remove the methyl groups and generate the hydrophilic regions selectively, a shadow metal mask covered c-PVP surface was exposed to ultraviolet-ozone (UVO) for 10 min. The detailed principles and the process of chemical patterning used in this study were described in our previous study<sup>18</sup>. Figure 1(b) describes the patterning process of TIPS-pentacene solution. The widths of the hydrophilic wetting regions were controlled in a mesoscale of 50 - 500 μm. Subsequently, a 2 wt. % TIPS-pentacene solution dissolved in anisole was blade coated onto the c-PVP at 60 °C<sup>24</sup>. The TIPS-pentacene solution was captured between the blade and the substrate by capillary force and coated on the c-PVP insulator surface. It was coated directionally at various speeds of 0.1, 0.3, and 0.5 mm/s and spontaneously deposited on the hydrophilic c-PVP region. An image of the patterned TIPS-pentacene is shown in Figure 1(c). Red arrows indicate the coating direction. Finally, 50 nm of Au was thermally deposited at a rate of 0.1 nm/s to form the source and drain electrodes. Channel length was 100 µm and the channel width depended on the patterned width of TIPS-pentacene thin films. The completed OTFTs were measured at room temperature under ambient pressure in a dark environment.

#### Results and discussion

To describe blade coated TIPS-pentacene structure and define the contact line curvature-induced molecular misorientation angle  $\theta_1$ , a 3D atomic force microscope (AFM) image of TIPS-pentacene was recorded as shown in Fig. 2. TIPS-pentacene was blade coated at the speed of 0.3 mm/s with a substrate temperature of 60 °C, and a blade gap of 200  $\mu$ m. For organic semiconductors,  $\pi$ - $\pi$  stacking structure of molecules facilitates charge transport<sup>9,25</sup>. Theoretically, the  $\pi$ - $\pi$  stacking direction of solution-processed small molecules follows the direction of solution evaporation which is the same as the coating direction for MGC methods<sup>9,26</sup>. MGC methods form a well aligned and continuous molecular stacking of TIPS-pentacene parallel to the coating direction due to their intrinsic directionality. Needle-shaped crystalline domains with 3  $\mu$ m width and 30 nm thickness were observed in this study as shown in Fig. 2. The long axis of the needle-shaped TIPS-pentacene crystalline domains was parallel to [210] as well as the crystal growth direction (blue arrow). Source and drain electrodes are usually designed to be parallel to the coating direction of OSC solutions for efficient field-effect charge transport., If molecular misorientation

is induced, however, the unintended angular mismatch between the coating direction (red arrow) and

117 crystal growth direction results in a disturbance of charge transport and a decrease in mobility. In Figure 2,

118  $\theta_1$  is the contact line curvature-induced misorientation angle which is the angle between coating direction

and crystal growth direction.

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The morphological characteristics of surface energy patterned TIPS-pentacene thin films were observed.

Figure 3 display schematic and the corresponding cross-polarized optical microscope (CPOM) images of

122 patterned TIPS-pentacene at varying pattern widths. Red arrows in the schematic and CPOM images

123 indicate the coating direction, and the yellow arrow in the CPOM images indicates the crystal growth

direction, which is the [210] direction of the TIPS-pentacene molecules. Regions 1 and 2 are the edge and

middle sections of the patterned TIPS-pentacene thin films. The scale bars in the CPOM images are 50

126 μm. The TIPS-pentacene solution was coated at different speeds of 0.1, 0.3, and 0.5 mm/s. As shown in

Figure 3, the crystal texture and thickness vary with increasing coating speed, from long, wide and thick

128 crystallites to short, narrow and thin crystallites. The molecular misorientation was observed in both

regions 1 and 2 regardless of the coating speeds and widths.

130 To convey the effect of contact line curvature-induced misorientation on the pattern width, the contact

line curvature-induced misorientation angles at various pattern widths are shown in Fig. 4(a). In this study,

132 contact line curvature-induced misorientation angles and OTFTs were studied at a coating speed of 0.3

mm/s because, at that speed, the highest crystallinity and best alignment of TIPS-pentacene were obtained,

and as a result, the highest mobility of the OTFTs was observed<sup>27</sup>. The misorientation angle of

unpatterned layers occurring due to fluid-flow was 9.87±2.13°. When the TIPS-pentacene was deposited

on the confined hydrophilic wetting region of 500 μm width, the misorientation angle increased to

15±3.61°. It increased more to 18±3.24° at the pattern width of 300 μm. By contrast, it began to decrease

with a decrease in the pattern width from 300 μm. The misorientation angles of 13.63±1.08° and

 $7.75\pm1.14^{\circ}$  were observed at the widths of 100 and 50  $\mu$ m, respectively. Interestingly, the misorientation

angle of patterned TIPS-pentacene at  $50~\mu m$  width was smaller than that of the unpatterned layer. These

results might have originated from the different contact line curvature of varying pattern widths.

Figure 4(b) shows several of the forces acting in a blade coating solution. First, capillary force helps in capturing the solution between substrate and blade head, and the surface tension makes a meniscus line. In addition, there is attraction between solution and wetting surface due to the hydroxyl group on the c-

PVP surface which generates high surface energy, so a solution in contact with the wetting surface remains on the wetting regions when the blade moves. There are dewetting regions outside of the wetting regions and the methyl group of the dewetting region forms a repulsive force between the hydrophobic

regions and the methyl group of the dewetting region forms a repulsive force between the hydrophobic surface and TIPS-pentacene solution (Figure 4(c)). The complexity of the forces and the different

influences of these forces at varying pattern widths result in different contact line curvature-induced molecular misorientations while blade coating. When the pattern is narrow, as in the 50 µm width, the

solution on the wetting region is too small compared with the main solution captured between the blade

and the surface, so the surface tension is dominant resulting in a high  $\theta_2$  which is the angle induce the molecular misorientation in patterned layer. In addition, fewer nucleates in the wider patterns than in the

unpatterned layer may induce well-oriented molecular stacking<sup>6</sup>. In summary, the patterned TIPS-

pentacene on the 50  $\mu$ m width showed the lowest misorientation angle  $\theta_1$ . When the pattern width is large,

the amount of solution on the wetting region and the molecules sited at the center of the wetting region

are predominantly affected by the attractive force but scarcely affected by the repulsive force. This results in a high contact line curvature, a small  $\theta_2$ , and a large  $\theta_1$ . As the pattern width increases beyond 300, the

repulsive forces cannot dominate most molecules except those sited at the edge due to the wide

hydrophilic region, so the contact line curvature decreases again and results in a large  $\theta_2$  and a small  $\theta_1$  as

shown in Figure 4(a).

We fabricated OTFTs to demonstrate the impact of contact line curvature-induced molecular

misorientation on the OTFT electrical performance. Figure 5 (a)-(e) shows the transfer curves of the 50,

164 100, 300, and 500 μm patterned OTFTs, and the unpatterned OTFTs coated at the speed of 0.3 mm/s. The

165 corresponding field-effect mobilities were 0.317, 0.240, 0.216, 0.267 and 0.276 cm<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup>. As the pattern

width increased up to 300  $\mu$ m, the mobility decreased from 0.317 to 0.216 cm<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup>. In contrast, the

mobility increased again from 0.216 to 0.276 cm<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup> as the pattern width increased from 300 µm. It

exhibited a tendency opposite to the misorientation angle graph (Figure 4(a)) as shown in Figure 6. The

169 contact line curvature-induced misorientation angle affected the charge transport properties and therefore

the mobility of OTFTs.

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#### 172 Conclusions

- We investigated the morphological characteristics and the molecular misorientation effect of surface
- energy patterned TIPS-pentacene deposited by means of blade coating. We demonstrated that contact line
- 175 curvature-induced molecular misorientation occurs only in patterned OSCs coated using an MGC method
- and is highly dependent on the pattern width. The lowest molecular misorientation angle of 7.7° occurred
- in a 50 µm pattern width. This was due to the dominance of surface tension and the generation of fewer
- nuclei resulting in the highest mobility of 0.317 cm<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup>. The highest misorientation angle was induced
- in a 300 µm pattern width of due to the dominance of repulsive and attractive forces compared to other
- forces. The corresponding OTFTs exhibited the lowest mobility of 0.216 cm<sup>2</sup>V<sup>-1</sup>s<sup>-1</sup>. We expect this work
- will provide an optimized pattern width for small-molecule OSCs to achieve the most effective charge
- will provide an optimized pattern width for small-molecule OSCs to achieve the most effective charge
- transport properties and to maximize the field-effect mobility of OTFTs.

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### Acknowledgments

- 185 This research was supported by the BK21 Plus project funded by the Ministry of Education, Korea
- 186 (21A20131600011). This research was also supported by the Basic Science Research Program through
- the National Research Foundation of Korea (NRF) funded by the Ministry of Science and ICT
- 188 (2018R1A2B6008815).

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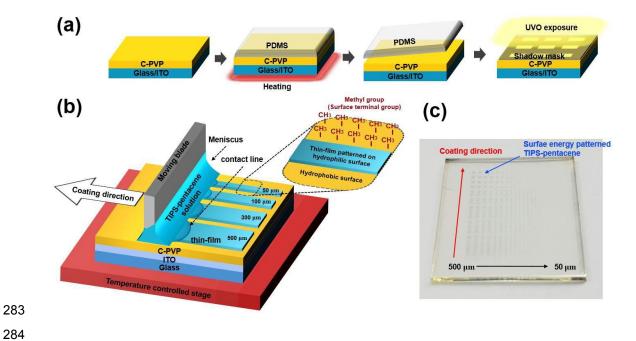


Figure 2. 3D AFM image of TIPS-pentacene crystalline domain and the schematic defining the

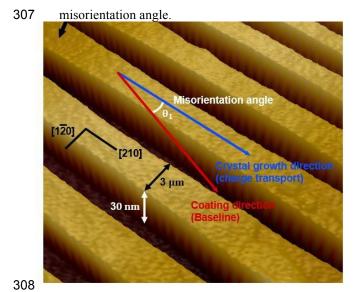


Figure 3. (a) Schematic illustration of patterned TIPS-pentacene thin films and (b) corresponding CPOM images for various coating speeds and various widths.

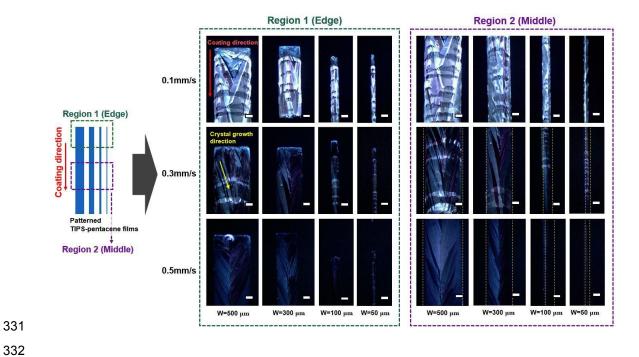
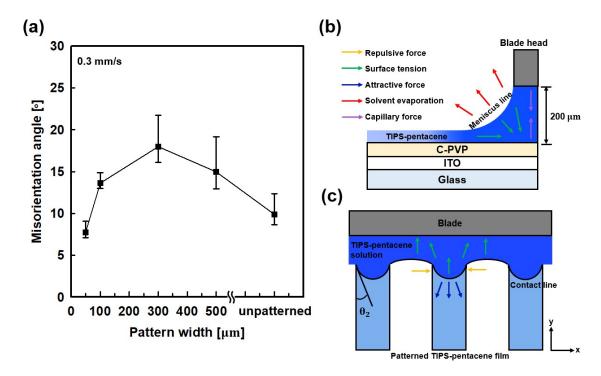
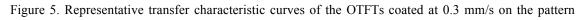


Figure 4. (a) Molecular misorientation angles of patterned TIPS-pentacene for various pattern width. Schematic illustrations of (b) side view and (c) top view of meniscus-guided coating of TIPS-pentacene.





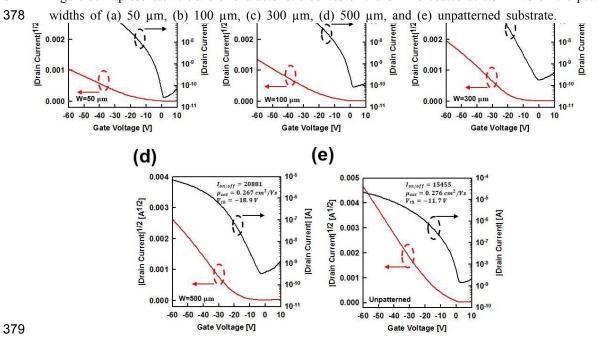


Figure 6. Average field-effect mobilities of OTFTs fabricated observed from surface energy patterned TIPS-pentacene thin films for various pattern widths.

